

	Application No.	Applicant(s)
	09/750,007	HARA ET AL.
Notice of Allowability	Examiner	Art Unit
	Kim-Kwok CHU	2653
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>Amendment filed on 11/15/2004</u> .		
2. The allowed claim(s) is/are 10-14 which are renumbered as 1-5 respectively.		
3. The drawings filed on 27 October 2000 are accepted by the Examiner.		
4.		
Attachment(s)  1. Notice of References Cited (PTO-892)  2. Notice of Draftperson's Patent Drawing Review (PTO-948)  3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6.  Interview Summary Paper No./Mail Da 8), 7.  Examiner's Amend	Patent Application (PTO-152)  (PTO-413),  Ite  ment/Comment  ent of Reasons for Allowance

## Allowable Subject Matter

- 1. Claims 10-14 are allowable over prior art .
- 2. The following is an Examiner's statement of reasons for the indication of allowable subject matter based on the Amendment filed on November 15, 2004.

As in claim 10, the prior art of record fails to teach or fairly suggest a method of producing a micro mirror having the following steps:

- (a) a first step at which a material for the hinges are formed as layer on one main side of a substrate material for the frame and mirror substrate;
- (b) a second step at which a resist layer is formed on the other main side of the substrate material on which a mirror surface is formed; and
- (c) a third step at which the frame and mirror substrate are separated from each other by the dry etching using the resist layer as a mask.

The features indicated above, in combination with the other elements of the claims, are not anticipated by, nor made obvious over, the prior art of record.

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- 3. Any comments considered necessary by applicant must be submitted no later than the payment of the Issue Fee and, to avoid processing delays, should preferably accompany the Issue Fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."
- 4. Any response to this action should be mailed to: Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Or faxed to:

(703) 872-9306 (for formal communications intended for entry. Or:

(703) 746-6909, (for informal or draft communications, please label "PROPOSED" or "DRAFT")

Any inquiry of a general nature or relating to the status of this application should be directed USPTO Contact Center (703) 308-4357; Electronic Business Center (703) 305-3028.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kim CHU whose telephone number is (571) 272-7585 between 9:30 am to 6:00 pm, Monday to Friday.

Kim-Kwok CHU

Examiner AU2653 March 14, 2005

(571) 272-7585

TAN DINH
PRIMARY EXAMINER